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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/605,052 09/05/2003		Cheng-Sung Wei	TSTP0016USA	2051
27765	7590 09/21/2005	EXAMINER		
	IERICA INTELLECTUA	AHMED, SHAMIM		
P.O. BOX 506	5			
MERRIFIELD, VA 22116			ART UNIT	PAPER NUMBER
		•	DATE MAILED: 09/21/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

		Applicat	ion No.	Applicant(s)			
Office Action Summary		10/605,0	052	WEI ET AL.			
		Examine	er .	Art Unit			
		Shamim	Ahmed	1765			
Period for I	The MAILING DATE of this commun Reply	ication appears on th	e cover sheet with the c	orrespondence address			
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).							
Status							
1)⊠ R	esponsive to communication(s) file	ed on 05 September	2003.				
	This action is FINAL . 2b)⊠ This action is non-final.						
3)□ Si	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
cl	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition	of Claims						
4)⊠ C	laim(s) <u>1-12</u> is/are pending in the	application.					
4 a	4a) Of the above claim(s) is/are withdrawn from consideration.						
5)□ C	Claim(s) is/are allowed.						
6)⊠ C	☑ Claim(s) <u>1-12</u> is/are rejected.						
7)□ C	Claim(s) is/are objected to.						
8)□ C	8) Claim(s) are subject to restriction and/or election requirement.						
Application	Papers						
9) The specification is objected to by the Examiner.							
10)⊠ The drawing(s) filed on <u>05 September 2003</u> is/are: a)□ accepted or b)⊠ objected to by the Examiner.							
A	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
	Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority und	der 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of:							
	Certified copies of the priority						
	☐ Certified copies of the priority		- •	•			
3.	3. Copies of the certified copies of the priority documents have been received in this National Stage						
* \$00	application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the partition applies not received.						
* See the attached detailed Office action for a list of the certified copies not received.							
Attachment(s)							
1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413)							
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) 5) Notice of Informal Patent Application (PTO-152)							
3) LI Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) 5) LI Notice of Informal Patent Application (PTO-152) Paper No(s)/Mail Date							
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DETAILED ACTION

Specification

1. The disclosure is objected to because of the following informalities: There are typographic error such as sentences without having gap in between two words such as: in last line at page 1, at paragraph 0005, "aplurality", at page 2, paragraph 0006, the use of "havingan" and asurface" and at paragraph 0008, the use of "18cconnected". Applicants are advised to review similar typographic error in the entire application.

Appropriate correction is required.

Drawings

2. Figure 1 should be designated by a legend such as --Prior Art-- because only that which is old is illustrated. See MPEP § 608.02(g). Corrected drawings in compliance with 37 CFR 1.121(d) are required in reply to the Office action to avoid abandonment of the application. The replacement sheet(s) should be labeled "Replacement Sheet" in the page header (as per 37 CFR 1.84(c)) so as not to obstruct any portion of the drawing figures. If the changes are not accepted by the examiner, the applicant will be notified and informed of any required corrective action in the next Office action. The objection to the drawings will not be held in abeyance.

Claim Objections

3. Claim 1 objected to because of the following informalities: in claim 1, lines 7-8, the use of the unit of inches (") in the phrase of " an inner diameter zone having a radius between 0.65" and 0.78" of the disk substrate" is not possible in that range in a magnetic disk drive. Appropriate correction is required.

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4. The claims 4,6,8-10 are objected to because the words are crowded too closely together, making reading difficult. Substitute claims with gaps in between words are required.

- 5. In claim 4, the word "disksubstratecomprises" requires gap in between words and should be written, as "disk substrate comprises".
- 6. In claims 6, there should be gap in between "4" and "further. Similar analysis applies for the claims 8-10.

Appropriate correction is required.

Claim Rejections - 35 USC § 103

- 7. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 8. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

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9. Claims 1-12 are rejected under 35 U.S.C. 103(a) as being unpatentable over Grubb et al (6,433,306) in view of Chen et al (5,987,391).

Grubb et al teach a process of texturing a surface of a disk to eliminate the effects of stiction, the metal disk surface is laser textured to form a plurality of grooves, bumps prior to applying thin magnetic film (col.11, lines 4-18).

Grubb et al also teach that the texturing comprises pulsed laser to texture the disk substrate of aluminum using a beam wavelength of 1064nm and pulse energy of about 4 μ J and pulse width range of about 10-200 nsec (col.11, lines 19-50).

Grubb et al fail to explicitly teach the claimed inner diameter along with the claimed type of laser.

However, Chen et al teach an improved process of forming bumps with height reduction with optimum topography for laser textured bumps using aNd-YVO₄ solid state laser having wavelength of 1064 nm with desired radius of the curvature (col.3, lines 44-53 and example 1 in col.4, lines 65-col.5 and table 1 in col.6).

Modified Grubb et al do not teach the claimed radius of the curvature or depression.

However, It would have been obvious to have the similar result because all the process constituents are similar as the instant invention and expected to have the similar effect.

Therefore, it would have been obvious to one of ordinary skilled in the art at the time of claimed invention to employ Chen et al's teaching into Grubb et al's process for

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efficiently and accurately texturing the disk substrate with desired result as taught by Chen et al.

Conclusion

10. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Yamazaki et al (2002/0187594) and Kuo et al (2001/0023856) disclose a process of texturing disk substrate using pulsed laser beam.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shamim Ahmed whose telephone number is (571) 272-1457. The examiner can normally be reached on M-Thu (7:00-5:30) Every Friday Off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine G. Norton can be reached on (571) 272-1465. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Shamim Ahmed Primary Examiner Art Unit 1765

SA September 18, 2005